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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of:

NAKAMURA, Yasunori, et al.

Group Art Unit: 1713

Serial No.: 10/629,857

Examiner: William K. Cheung

Filed: July 30, 2003

P.T.O. Confirmation No.: 6154

FOR: POLYPROPYLENE-BASED RESIN COMPOSITION FOR A METALLIZED FILM, FILM USING THE SAME TO BE SUBJECTED TO METALLIZING AND METALLIZED FILM USING THE SAME

REQUEST FOR RECONSIDERATION

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Date: April 12, 2006

Sir:

Reconsideration of the rejection contained in the Office Action dated January 13, 2006, in view of the following comments is requested.

In the Office Action, claims 1-3, 5-8 and 10-12 again were rejected under 35 USC § 102(b) as being anticipated by, or alternatively, under 35 USC 103(a) as being obvious over, the patent to Chatterjee. In making this rejection, it was alleged that the Chatterjee patent teaches a resin composition for metallized films formed of components which fall within the scope of the noted claims. In so doing, it was asserted that at least some of the properties (a-1) through (a-6) of the propylene random copolymer (A) and the recited properties for polyethylene resin (B), although not specifically disclosed, would be inherent in the compositions according to the cited patent. Reconsideration of this rejection in view